

# Corrosion Mitigation for Gen 3 CSP Systems

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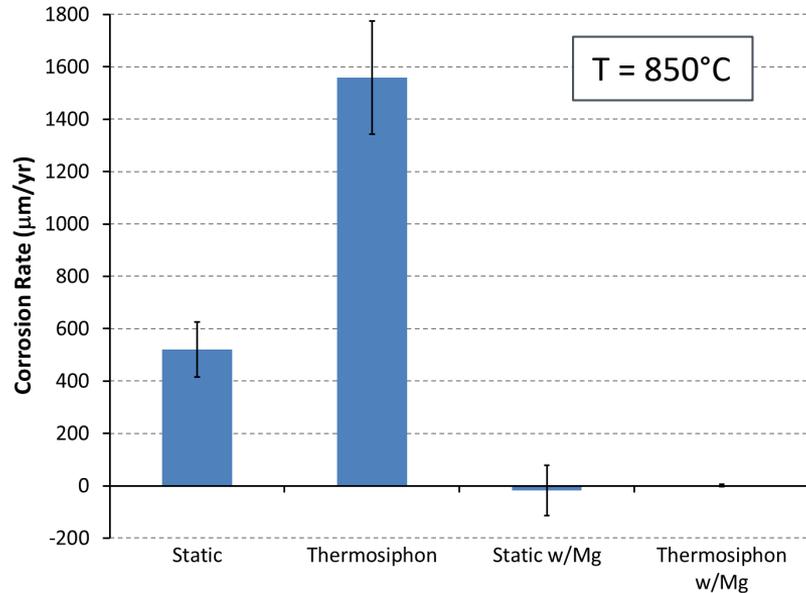
Luke Olson

Chris Dandeneau

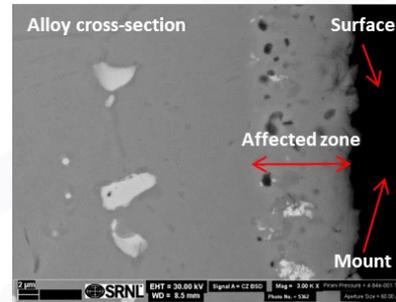
Michael Martinez-Rodriguez

Scott Greenway

# Assessment of Cathodic Protection Effectiveness



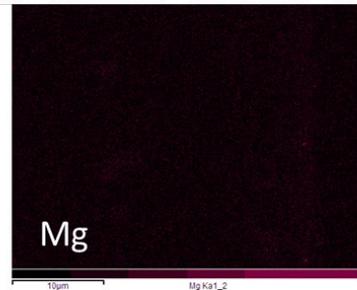
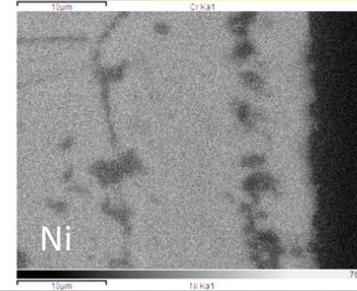
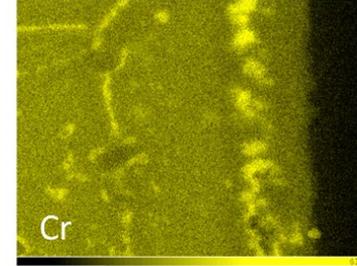
- Isothermal corrosion for Haynes 230 in  $MgCl_2$ -KCl is 35 times higher than the 15 microns per year target
- Non-isothermal corrosion for Haynes 230 with only free convection is over 100 times higher than the target



SEM of Cross-section

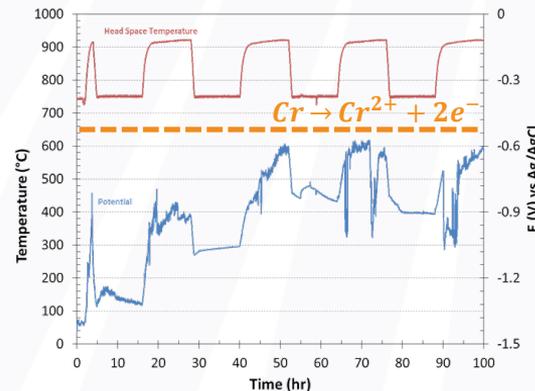
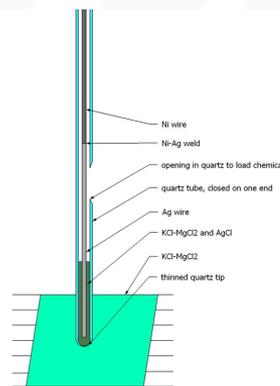
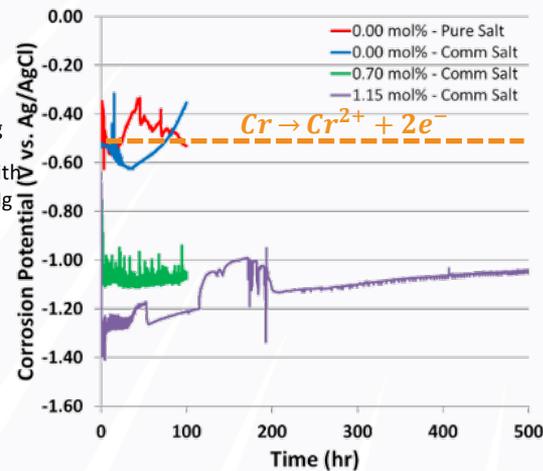
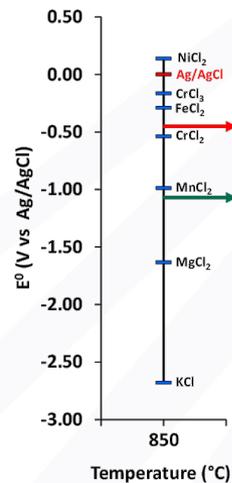
- Tests with Mg as a corrosion inhibitor species eliminated weight loss in the samples for static test
- An improved understanding of the long term behavior of systems with Mg corrosion inhibition is needed along with a method to reliably control the amount of Mg present in a system

EDS X-ray maps of cross-section



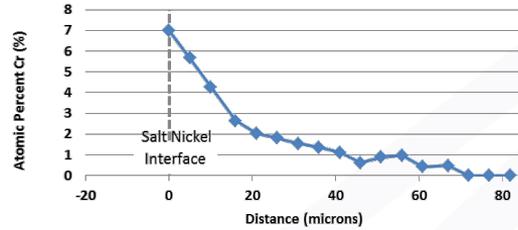
# Potential Monitoring for Corrosion Mechanism in $MgCl_2$ -KCl using Mg

- Corrosion mitigation is thermodynamic and can be monitored looking at sample potential versus a reference electrode
- SRNL used thermodynamic modeling to determine the equilibrium potentials for elements in the system
- The equilibrium potential for Cr oxidation/reduction is near -0.5 V vs. Ag/AgCl in molten chlorides at 850 °C
- Mg has an equilibrium potential of -1.5 V vs. Ag/AgCl and can prevent oxidation of Cr
- Haynes 230 samples in salt with no Mg had potentials that were above -0.5 V for extended periods of time and these samples showed typical corrosion levels
- Haynes 230 samples in salt with Mg had potentials well below -0.5 V for the entire experimental period and these samples showed no statistically significant weight change
- System electrochemical potential increased with operating temperature, which demonstrates that high temperature conditions have the ability to cause more corrosion
- Using reference electrodes can be used for control of redox agents

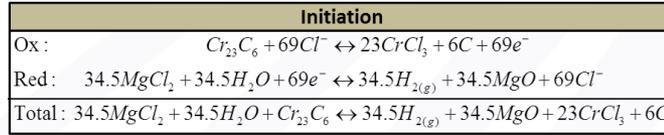
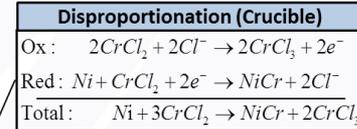


# Introduction: Corrosion Mechanism in $MgCl_2$ -KCl (Previous SRNL SunShot Project)

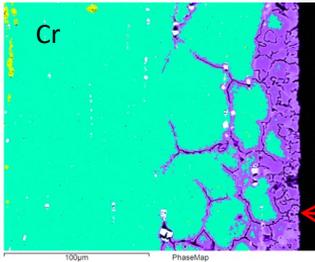
Corrosion initiation step can be caused by impurities such as moisture or oxygen that add a finite concentration of chromium chloride to the salt



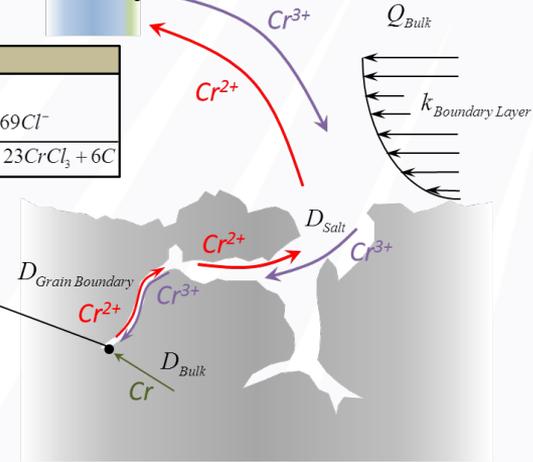
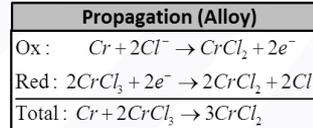
EDS line scan from a cross-section of a Ni crucible containing a single Incoloy-800H coupon



EDS X-ray map of Cr from Haynes 230 cross-section

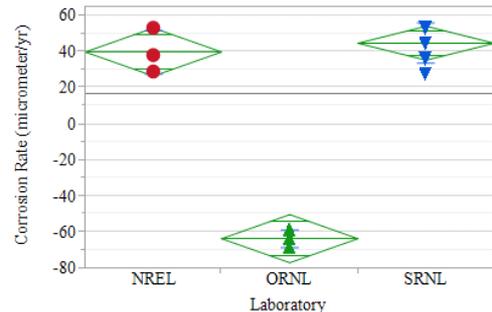


Alloy Surface



# Task 1.0: Exchange of Samples and Data with Project Cohorts – Comparison Between National Labs

## NREL vs ORNL vs SRNL



- The test of the null hypothesis of equal variances cannot be rejected at the 5% significance level; thus, there is **no indication of a difference in variances across the three labs.**

### Tests that the Variances are Equal

Level	Count	Std Dev	MeanAbsDif to Mean	MeanAbsDif to Median
NREL	3	12.06275	8.600000	7.966667
ORNL	3	4.65224	3.155556	3.100000
SRNL	6	10.97500	8.677778	8.666667

Test	F Ratio	DFNum	DFDen	Prob > F
O'Brien[.5]	0.7174	2	9	0.5139
Brown-Forsythe	0.7593	2	9	0.4958
Levene	1.3131	2	9	0.3160
Bartlett	0.7359	2	.	0.4791

Warning: Small sample sizes. Use Caution.

### Means Comparisons

Comparisons for all pairs using Tukey-Kramer HSD Connecting Letters Report

Level	Mean
SRNL A	44.66667
NREL A	39.80000
ORNL B	-63.56667

Levels not connected by same letter are significantly different.

### Oneway Anova Summary of Fit

Rsquare	0.964734
Adj Rsquare	0.956898
Root Mean Square Error	10.20109
Mean of Response	16.39167
Observations (or Sum Wgts)	12

### Analysis of Variance

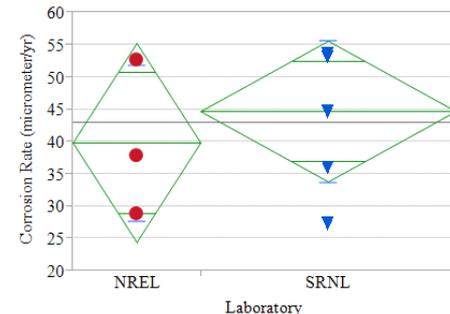
Source	DF	Sum of Squares	Mean Square	F Ratio	Prob > F
Laboratory	2	25620.709	12810.4	123.1028	<.0001*
Error	9	936.560	104.1		
C. Total	11	26557.269			

### Means for Oneway Anova

Level	Number	Mean	Std Error	Lower 95%	Upper 95%
NREL	3	39.8000	5.8896	26.48	53.12
ORNL	3	-63.567	5.8896	-76.89	-50.24
SRNL	6	44.667	4.1646	35.25	54.09

Std Error uses a pooled estimate of error variance

## NREL vs SRNL



- The test of the null hypothesis of equal means is rejected at the 5% significance level; with the additional test results indicating that **SRNL and NREL show no difference in their mean corrosion rates, while both labs are different from ORNL.**

### Oneway Anova Summary of Fit

Rsquare	0.050358
Adj Rsquare	-0.08531
Root Mean Square Error	11.29648
Mean of Response	43.04444
Observations (or Sum Wgts)	9

### t Test SRNL-NREL

Assuming equal variances

Difference	4.867	t Ratio	0.609261
Std Err Dif	7.988	DF	7
Upper CL Dif	23.755	Prob >  t	0.5616
Lower CL Dif	-14.022	Prob > t	0.2808
Confidence	0.95	Prob < t	0.7192

### Analysis of Variance

Source	DF	Sum of Squares	Mean Square	F Ratio	Prob > F
Laboratory	1	47.36889	47.369	0.3712	0.5616
Error	7	893.27333	127.610		
C. Total	8	940.64222			

### Means for Oneway Anova

Level	Number	Mean	Std Error	Lower 95%	Upper 95%
NREL	3	39.8000	6.5220	24.378	55.222
SRNL	6	44.6667	4.6118	33.762	55.572

Std Error uses a pooled estimate of error variance

### Tests that the Variances are Equal

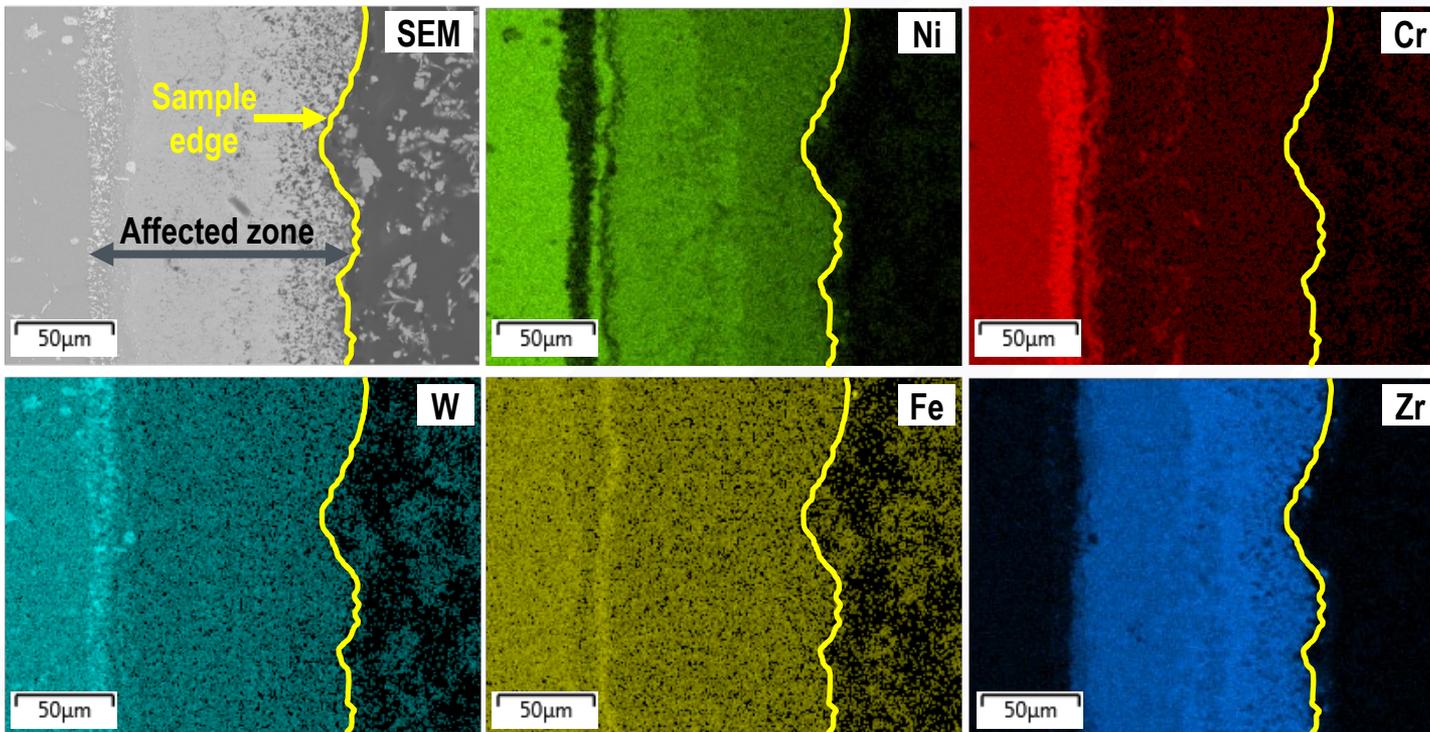
Level	Count	Std Dev	MeanAbsDif to Mean	MeanAbsDif to Median
NREL	3	12.06275	8.600000	7.966667
SRNL	6	10.97500	8.677778	8.666667

Test	F Ratio	DFNum	DFDen	p-Value
O'Brien[.5]	0.0522	1	7	0.8258
Brown-Forsythe	0.0185	1	7	0.8956
Levene	0.0004	1	7	0.9849
Bartlett	0.0221	1	.	0.8819
F Test 2-sided	1.2080	2	5	0.7465

Warning: Small sample sizes. Use Caution.

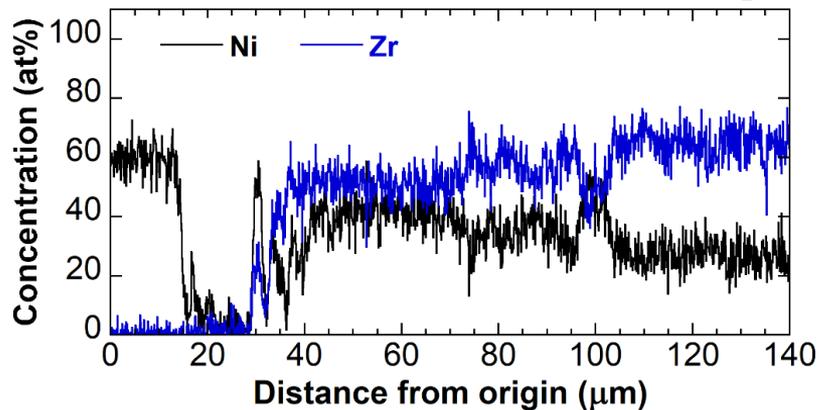
## Subtask 2.1.2: Self-Healing Coatings as Corrosion Inhibitors – Elemental Mapping of H230-G3-SRC-Zr4

- EDX mapping of cross-section confirms formation of Zr coating on Haynes 230
- Affected zone composed of Cr/W-rich region near bulk and Ni/Zr-rich regions closer to edge



## Subtask 2.1.2: Self-Healing Coatings as Corrosion Inhibitors – H230-G3-SRC-Zr4 Ni/Zr-rich Region

EDX analysis indicates presence of NiZr and NiZr<sub>2</sub> phases



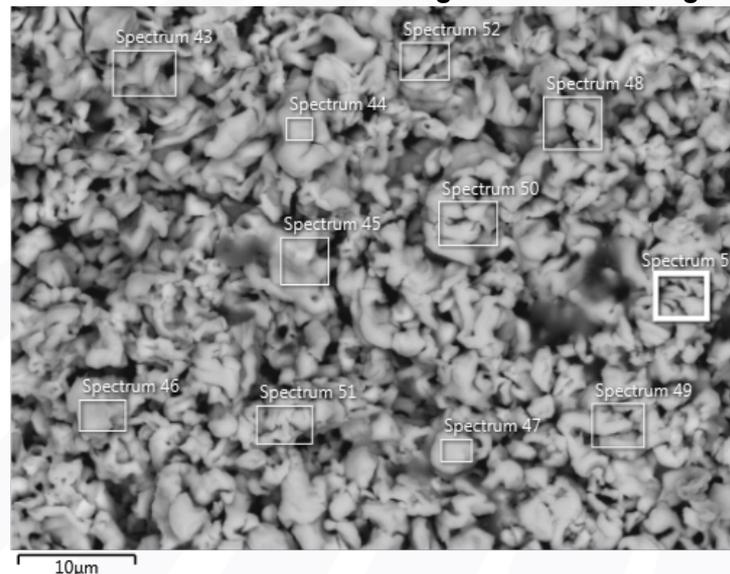
Between ~70 – 90 μm from edge

Parameter	Value
Average Zr Atomic Fraction	0.53 ± <0.1
NiZr Atomic Fraction	0.5

Within 30 μm of edge

Parameter	Value
Average Zr Atomic Fraction	0.67 ± <0.1 g
NiZr <sub>2</sub> Atomic Fraction	0.67

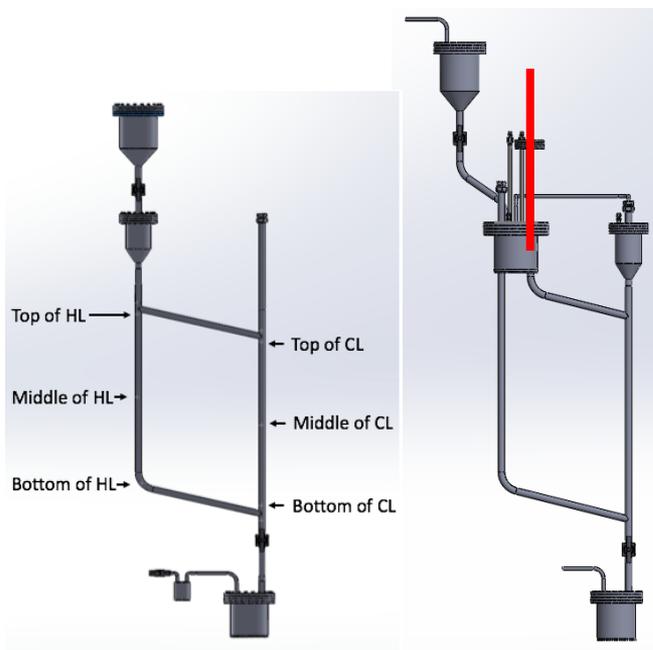
Point scans of surface near edge of Ni/Zr-rich region



Element	Mean Concentration (at%)	Standard Deviation (at%)
Ni	31.2	2.6
Cr	0.4	0.1
W	0.3	0.1
Zr	67.2	3.1

Zr atomic fraction within 2% of ideal NiZr<sub>2</sub> value

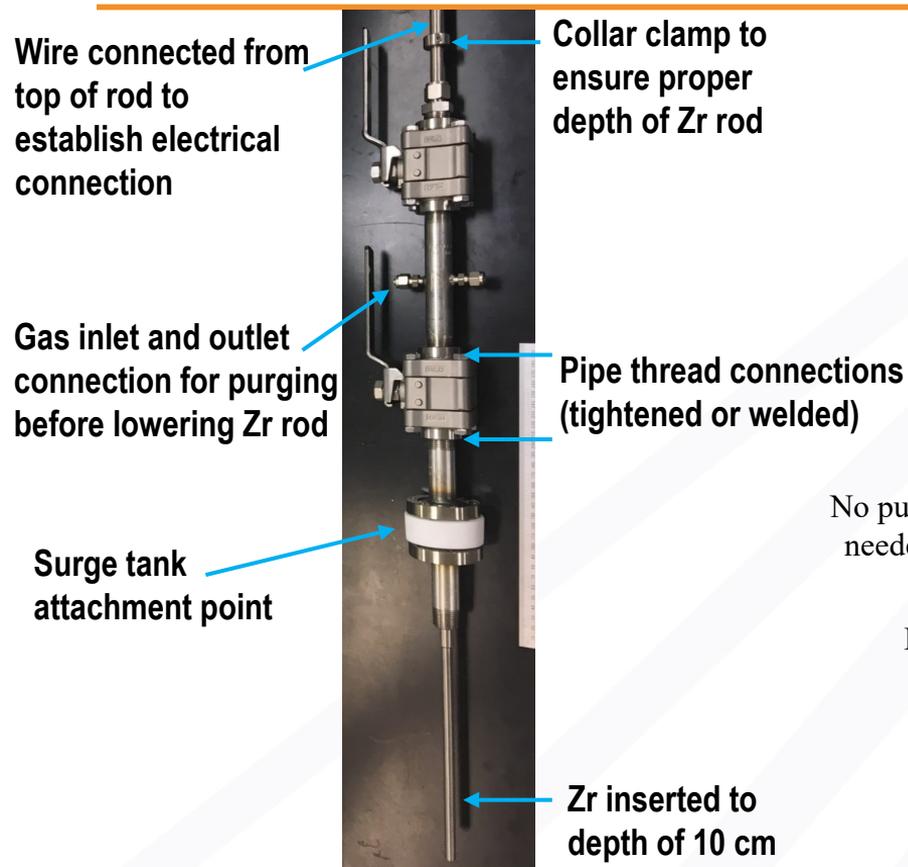
## Subtask 2.1.3: Design and Test a Getter Bed for a Thermosiphon Reactor in Collaboration with ORNL



ORNL provided drawing of old and new natural convection flow loop designs

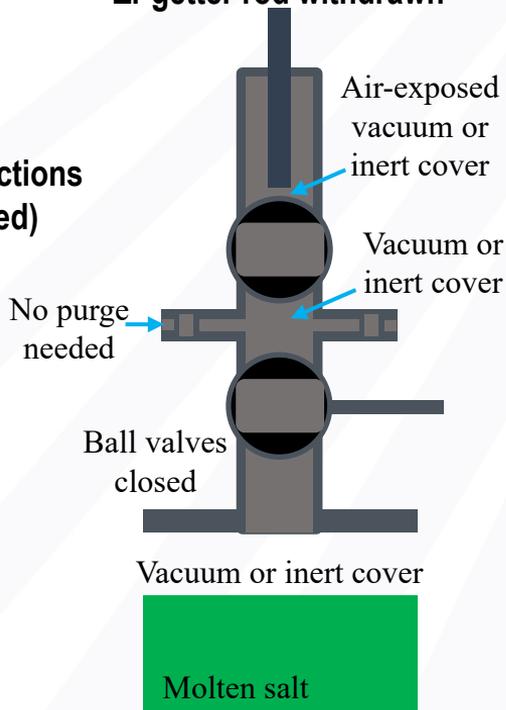
- SRNL provided a corrosion control solution in redesigned ORNL loop
  - Potential install location in red
- New flow loop design should be comparable to old design → compare old data with corrosion inhibited
- Two options have been designed
  - Zr getter rod
  - Electrolysis rod apparatus
- Zr rod will reduce corrosion by
  - 1) Galvanic protection
    - Zr rod more anodic than piping → corrode first if in electrical contact with loop
    - Zr in salt may coat pipe → galvanic buffer if rod withdrawn
  - 2) Redox control
    - $Zr^0 \rightarrow ZrCl_2 \rightarrow ZrCl_3 \rightarrow ZrCl_4$  occur prior to Cr oxidation → buffer against  $Cr^0 \rightarrow Cr^{2,3+}$
- Mg Electrolysis (in situ)
  - 1) Galvanic protection
    - Galvanic protection capability, can coat some walls if below melting point
    - $Mg^0$  is soluble (small) in the salt → buffer. May also present some galvanic protection
  - 2) Redox control
    - $Mg^0 \rightarrow Mg^{2+}$  will prevent  $Cr^0 \rightarrow Cr^{2,3+}$
    - $Mg^0$  is soluble (small) in the salt, and this solubility will act as a buffer.
  - 3) Oxide sink:  $MgO$  → most stable oxide in system

## Subtask 2.1.3: Design and Test a Getter Bed for a Thermosiphon Reactor in Collaboration with ORNL

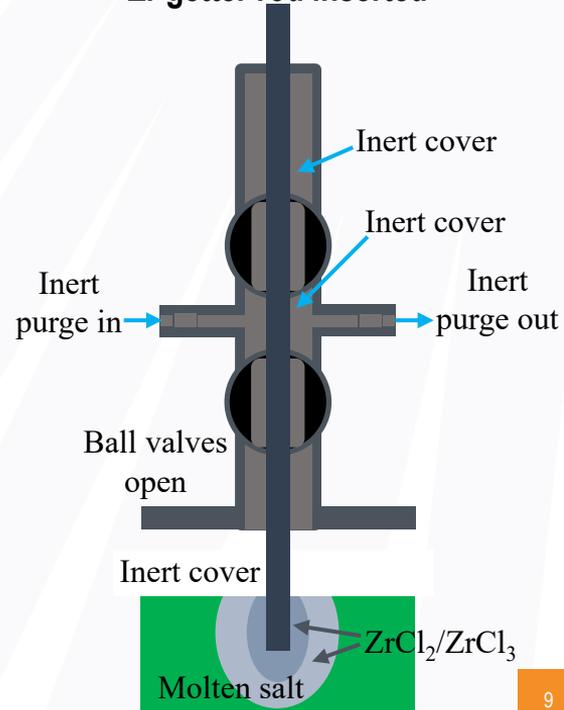


### Schematic of Zr gettering assembly with rod when inserted and withdrawn

Zr getter rod withdrawn

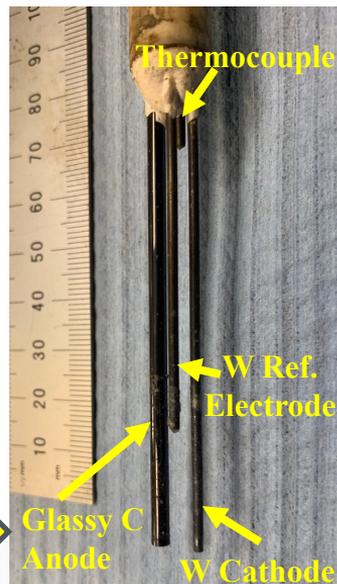


Zr getter rod inserted

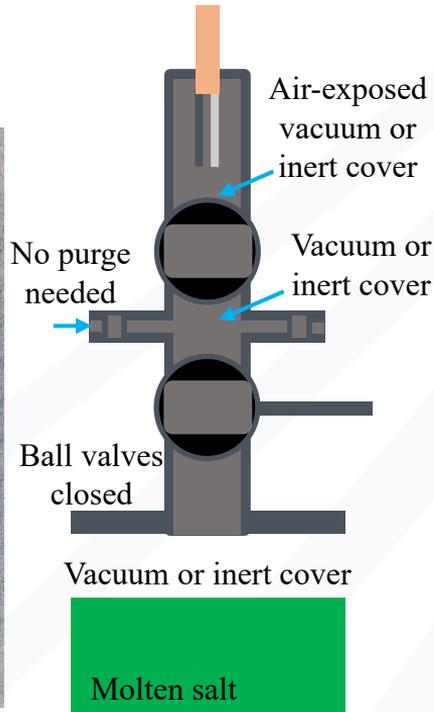


## Subtask 2.1.3: Design and Test a Getter Bed for a Thermosiphon Reactor in Collaboration with ORNL

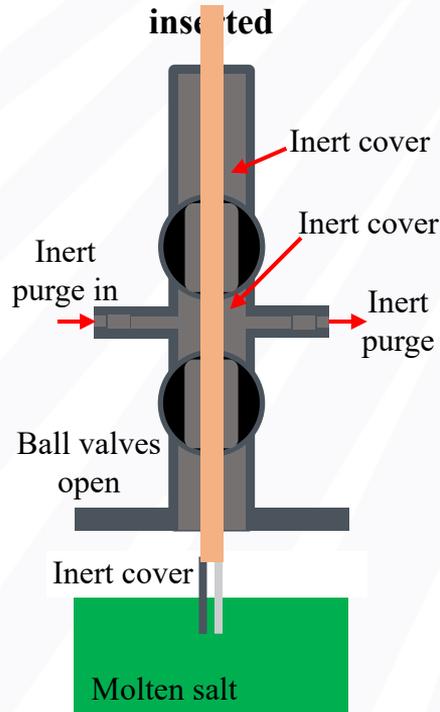
Enlarged view of electrode assembly



Electrode assembly withdrawn



Electrode assembly inserted



Electrode assembly inserted and polarized

